

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1180519	H2 or H?sub\$2 or hydrogen	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:07
L2	924058	O2 or O?sub\$2 or oxygen	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:08
L3	238102	1 and 2 and (catalyst or Ni or nickel or Pt or platinum or Pd or palladium)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:10
L4	212290	3 and (moisture or vapor or H2O or water or steam or H2O or "H.sub.2O" or "H.sub.2 O")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:36
L5	147234	3 and (@ad<="19970305" or @rlad<="19970305")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:16
L6	132278	4 and 5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:16
L7	80134	5 and (chamber or vessel or reactor or furnace)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:21
L8	75103	7 and 6	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:22
L9	8641	8 and (semiconductor or IC or (integrated adj circuit))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:26

L10	1707	9 and ((silicon or Si or wafer) same (oxidiz\$6 or oxidat\$6 or RTO))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:28
L11	1439	10 and (N2 or nitrogen or N ₂)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:28
L12	843	11 and ((moisture or vapor or H2O or water or steam or H2O or "H.sub.2O" or "H.sub.2 O") same (oxidat\$6 or oxidiz\$6 or RTO))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:35
L13	93563	1 same 2 same (moisture or vapor or H2O or water or steam or H2O or "H.sub.2O" or "H.sub.2 O")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:37
L14	396	12 and 13	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/16 13:37